

Accepted Manuscript

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M.A.N. Dewapriya, R.K.N.D. Rajapakse



PII: S0264-1275(18)30761-5
DOI: [doi:10.1016/j.matdes.2018.10.006](https://doi.org/10.1016/j.matdes.2018.10.006)
Reference: JMADE 7420
To appear in: *Materials & Design*
Received date: 29 July 2018
Revised date: 4 October 2018
Accepted date: 4 October 2018

Please cite this article as: M.A.N. Dewapriya, R.K.N.D. Rajapakse , Atomistic and continuum modelling of stress field at an inhomogeneity in graphene. *Jmade* (2018), doi:[10.1016/j.matdes.2018.10.006](https://doi.org/10.1016/j.matdes.2018.10.006)

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M. A. N. Dewapriya* and R. K. N. D. Rajapakse

School of Engineering Science, Simon Fraser University, Burnaby, Canada

*Corresponding author. E-mail: mandewapriya@sfu.ca (Nuwan Dewapriya)

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